


Name: Enrolment No:			
UPES End Semester Examination, May 2025			
Programme Name : BTech ECE Course Name : Nano-Electronics Devices Course Code : ECEG3063P_3 Nos. of page(s) : 2		Semester : 6 Time : 03 hrs Max. Marks: 100	
Instructions: Use of scientific calculators is allowed Q -11 is Compulsory; students can choose any one option in Q-10. In Q-9 Student can choose any one option			
SECTION A (5Qx4M=20Marks)			
S. No.		Marks	CO
Q 1	Define De-wetting in lithography-based fabrication. Provide one example where it is useful.	4	CO1
Q 2	Explain the principle of Molecular Electronics? List its applications in modern devices.	4	CO1
Q 3	Describe Hot Embossing process.	4	CO2
Q 4	Explain the working of a bulk micromachining process.	4	CO1
Q 5	What are the limitations of resolution in lithography? List two methods to enhance it.	4	CO2
SECTION B (4Qx10M= 40 Marks)			
Q 6	Describe the working of Flip-chip bonding using suitable diagrams.	10	CO3
Q 7	Explain the Sputtering and Chemical Vapor Deposition (CVD) techniques. Compare both in terms of applications and limitations.	10	CO1
Q8	Explain the working of bubble micro pump with suitable diagrams.	10	CO2
Q 9	Explain, micro-stereo lithography process in detail. OR Discuss accelerometer sensors in MEMS with working principle and applications.	10	CO2
SECTION-C (2Qx20M=40 Marks)			
Q 10	a) Compare Microfluidic mixers: passive and active types. OR	20	CO2

	b) Explain the various sensor applications of MEMS/NEMS systems in biomedical devices. Give suitable examples.		
Q 11	a) Using a flow-chart, explain photo-lithography process. b) Explain the fabrication and applications of Single-Electron Transistors (SETs).	20	CO3